

Notice of References Cited	Application/Control No. 10/613,574	Applicant(s)/Patent Under Reexamination OOTSUKA ET AL.	
	Examiner Sylvia R. MacArthur	Art Unit 1763	Page 1 of 1

U.S. PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
	A	US-6,444,957	09-2002	Kitagawa et al.	219/444.1
	B	US-6,693,789	02-2004	Inazumachi et al.	361/234
	C	US-2002/0006678	01-2002	Inazumachi et al.	438/20
	D	US-2002/0023914	02-2002	Kitagawa et al.	219/444.1
	E	US-2004/0074606	04-2004	Ootsuka et al.	156/345.47
	F	US-6,872,908	03-2005	Ootsuka et al.	219/121.52
	G	US-2003/0071260	04-2003	Ootsuka et al.	257/44
	H	US-2004/0011287	01-2004	Ootsuka, Takeshi	118/715
	I	US-			
	J	US-			
	K	US-			
	L	US-			
	M	US-			

FOREIGN PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N					
	O					
	P					
	Q					
	R					
	S					
	T					

NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
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	V	
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	X	

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